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Organic solar cells

<https://www.futureentech.com>

<https://infinitypv.com/products/>

Organic photovoltaics (OPV)

- ✓ light weight and flexible to substrates;
- ✓ semitransparent for window-like applications;
- ✓ low manufacturing costs comparing with inorganic PVs, like silicone based cells
- ✓ low environmental impact;

<https://www.nature.com/news/>

Materials and blocking layer

energy levels of the materials from thin films

- air stable
- thickness insensitive
- high open circuit Voltage (1.05eV)

Electron blocking layer

In-situ sputtering experiment

DESY

PO3 beamline

Experiment parameters

- energy: 12.89 keV
- incident angle: 0.4°
- SDD: 2545 cm
- target: Al

averaged statistical information

non destructive for sample

buried structures

specular beam position $\alpha_f = \alpha_i$

Yoneda peak position $\alpha_f = \alpha_c$

horizon position $\alpha_f = 0$

direct beam position $\alpha_f = -\alpha_i$

Surface morphology before vs after sputtering

SEM

AFM

a) active layer

b) active layer + MoO₃

c) + 20 nm Al

d) + 20 nm Al

active layer a) and with 10 nm MoO₃ on top b); 20 nm AL sputtered on the active layer c) and on active layer with MoO₃ d).

In-situ GISAXS results

evolution of vertical cuts at $q_y=0$ without a) and with b) MoO₃ layer versus the effective film thickness δ ;

c) and d) show the corresponding evolution of horizontal cuts at Al Yoneda peak range.

horizontal line cuts q_y and the corresponding fits in the range of the Al Yoneda peak without and with MoO₃ layer versus the effective film thickness δ .

Conclusion

- Appearing of aluminum I peaks move from large to small q_y values with increasing δ , which can be assigned to Al clusters appearing during the sputter process.
- Faster formation of aluminum cluster on pure active layer than on MoO₃ layer.

